
**Implants for surgery —
Hydroxyapatite —**

**Part 3:
Chemical analysis and
characterization of crystallinity ratio
and phase purity**

AMENDMENT 1

*Implants chirurgicaux — Hydroxyapatite —
Partie 3: Analyse chimique et caractérisation du rapport de
cristallinité et de la pureté de phase*
AMENDEMENT 1

PROOF / ÉPREUVE



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CH-1214 Vernier, Geneva
Phone: +41 22 749 01 11
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This document was prepared by Technical Committee ISO/TC 150, *Implants for surgery*, SC 1 *Materials*.

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5.8.4

Change the text to the following:

The results shall be given by a dimensionless value representing the Ca:P atomic ratio expressed to the nearest two decimal places.

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